

Ion Beam Source L400





ЛЦМК.228.00.00.00

Extended ion source IBS-400 is a gas-discharge source of working gas ions with an energy of 300-2500 eV. The principle of operation is an accelerator with an anode layer (UAS).

IBS-400 is designed for a wide range of applications: ion cleaning, etching, polishing, surface modification.

Parameter	Value
Beam shape	rectangular, hollow
Beam size (L x W x T), mm * (Length x Width x Thickness)	370 x 42 x 5
Supply voltage, V * The average ion energy of the beam is approximately equal to half the supply voltage	500 – 5000
Maximum voltage, V	5500
Maximum beam current, mA * For working gas - argon at a flow rate of not more than 2.01/h	600
Maximum operating current, mA	1000
Maximum gas consumption, I / h	5,0
Maximum coolant consumption, I / min	1
Maximum working pressure in the chamber, Pa	10
Chamber working pressure range, Pa	0,001-1
Weight, kg	no more than 6

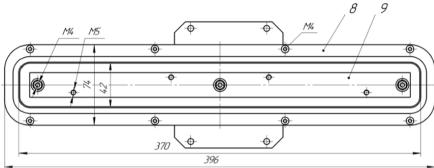
^{*} It is produced in several versions.

Website: https://vaclab.ru E-mail: vaclab@vaclab.ru Phone: 8(499)346-06-67 Address: LVT+ LLC, ELMA Technopark, Zelenograd, Moscow, Russia

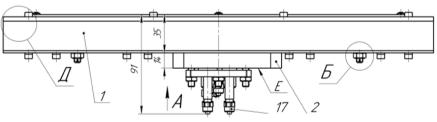


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